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6. Pump	212		TFO	0			100-450	IJII		7-	-5	7-	
5. Dep	210	TBD	servo to 1-10T	840			100-450	100-2000	to chamber	50-1000	100-500	100-25000	
4. SiH4 Soak	208	1 sec	servo to 1-10T				100-450	100-2000	to chamber	50-1000	100-500	100-25000	
3. Flow to Divert	204	1 to 5	servo to 1-10T	0			100-450	100-2000	to divert	50-1000	100-500	1000-25000	
2. NH3 Treat	206	5 to 40	servo to 1-10T		1-1000	1-1000	100-450	100-2000	to divert	20-1000	100-500	18000	1000-25000
1. Stab			servo to 1-10T		0		100-450	100-2000			100-500	1000-25000	
	Fig. 2 Step #	time, sec	Press, torr	Control	RF1	RF2	Temp, C	mils	SIH4 flow	SiH4	NH3	N2	